



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re **PATENT** application of:

Applicant:

K. R. Udayakumar et al.

Application No.:

10/620,516

For:

HYDROGEN BARRIER FOR PROTECTING FERROELECTRIC

CAPACITORS IN A SEMICONDUCTOR DEVICE AND METHODS

FOR FABRICATING THE SAME

Filing Date:

July 16, 2003

Examiner:

Sara W. Crane

Art Unit:

2811

REPLY TO OFFICE ACTION DATED MARCH 31, 2004

Mail Stop Non-Fee Amendment Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Dear Sir:

Favorable reconsideration of the above-identified application is respectfully requested in view of the following amendments and remarks.